



Advances in Environmental Pollution and Control Processes

Guest Editors:

Prof. Dr. Lingling Ma

Institute of High Energy Physics,
Chinese Academy of Sciences,
Beijing 100049, China

Dr. Yang Shao

Institute of High Energy Physics,
Chinese Academy of Science,
Beijing 100049, China

Dr. Min Luo

Institute of High Energy Physics,
Chinese Academy of Science,
Beijing, China

Message from the Guest Editors

With the rapid development of economies, the global ecological environment is facing unprecedented pressure. In order to realize sustainable development, investigating the causes for environmental pollution and treatment methods have attracted more and more attention.

This Special Issue of "Advances in Environmental Pollution and Control Processes" is the premier platform for the presentation of new advances and research results in the fields of theoretical, experimental, and applied environment pollution and control. This topic focuses on the new science and technologies for the major environmental issues and the latest research achievements and perspectives.

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Editor-in-Chief

Prof. Dr. Giancarlo Cravotto

Department of Drug Science and
Technology, University of Turin,
Via P. Giuria 9, 10125 Turin, Italy

Message from the Editor-in-Chief

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Processes Editorial Office
MDPI, St. Alban-Anlage 66
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